

Number	Hits	Search Text	DB	Time stamp
	57	(hafnium or titanium or tantalum or zirconium) same oligonucleotide	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:10
2	1	((hafnium or titanium or tantalum or zirconium) same oligonucleotide) same substrate same silicon	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:03
3	10	((hafnium or titanium or tantalum or zirconium) same oligonucleotide) same silicon	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:03
4	15	((hafnium or titanium or tantalum or zirconium) same oligonucleotide) same glass	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:03
5	4535	(hafnium or titanium or tantalum or zirconium) same chip	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:08
6	1	((hafnium or titanium or tantalum or zirconium) same chip) same oligonucleotide	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:08
7	1922	(hafnium or titanium or tantalum or zirconium) same (oligomer or dna or nucleic)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:10
8	311	((hafnium or titanium or tantalum or zirconium) same (oligomer or dna or nucleic)) same (silicon or glass)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:10
9	8	((hafnium or titanium or tantalum or zirconium) same (oligomer or dna or nucleic)) same (silicon or glass)) same chip	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:30
10	2	5631734[pn]	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:30
11	1289	(deposit\$5 or etch\$3) same oligonucleotide	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:33
13	0	((deposit\$5 or etch\$3) same oligonucleotide) same (array or chip)) same evaporation	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:32
12	198	((deposit\$5 or etch\$3) same oligonucleotide) same (array or chip)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:33
15	10	((evaporation) same oligonucleotide) same (array or chip)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:33
16	3	(sputtering) same oligonucleotide	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:37

17	51233	(base or acid) near10 etch\$3	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:38
18	5	((base or acid) near10 etch\$3) same oligonucleotide	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:38
19	1937	((base or acid) near10 etch\$3) same (chip or array)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:39
20	10	((base or acid) near10 etch\$3) same (chip or array)) same (nucleic or dna or oligonucleotide)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:39
21	51	((base or acid) near10 etch\$3) same (chip or array)) and (nucleic or dna or oligonucleotide)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:39
22	41	((base or acid) near10 etch\$3) same (chip or array)) and (nucleic or dna or oligonucleotide)) not (((base or acid) near10 etch\$3) same (chip or array)) same (nucleic or dna or oligonucleotide))	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:40
14	269	(evaporation) same oligonucleotide	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:57
23	0	6537755[pn] and evaporation	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:58
24	1	6537755[pn] and sputtering	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/05/17 19:58